



**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

<u>In re application of:</u> Cyril Cabral, Jr.	Filed: 11/21/2003
	Examiner: Kiesha L. Rose
Serial No. 10/707,117	Group Art Unit: 2822
<u>Title:</u> Interconnect Structure Diffusion Barrier With High Nitrogen Content	<u>Docket #:</u> FIS920030252US1

**AMENDMENT**

Commissioner of Patents & Trademarks  
Alexandria, VA 22313

Sir:

Responsive to the Office Action of 06/14/2005, please amend the above identified application as follows: